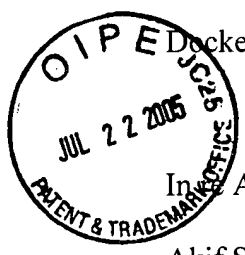


IPW



Docket No.: 050432-0395

PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of	:	Customer Number: 20277
	:	
Akif SULTAN, et al.	:	Confirmation Number: 6644
	:	
Application No.: 10/759,171	:	Group Art Unit: 2812
	:	
Filed: January 20, 2004	:	Examiner: Isaac, Stanetta D.
	:	

For: METHOD OF FORMING MINIATURIZED POLYCRYSTALLINE SILICON GATE  
ELECTRODES USING SELECTIVE OXIDATION

**REQUEST FOR RECONSIDERATION**

Mail Stop Request for Reconsideration  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Reconsideration of the rejection under 35 U.S.C. § 103 imposed in the Office Action  
dated June 27, 2005 is solicited in light of the following Remarks.